

ISO 14000 Certification for Selected Toshiba Facilities

Production Site		Certified Date	Certified No.
Domestic	Toshiba Yokkaichi Works	Feb. 02, 1996	EC95J1014 (JACO)
	Toshiba Kitakyushu Works	Sep. 24, 1996	EC96J1019 (JACO)
	Toshiba Oita Works	Oct. 29, 1996	EC96J1033 (JACO)
	Toshiba Microelectronics Center	Mar. 25, 1997	EC96J1088 (JACO)
	Toshiba Himeji Semiconductor Works	Jul. 28, 1997	EC97J1041 (JACO)
	Iwate Toshiba Electronics	Sep. 30, 1997	EC97J1092 (JACO)
	Toshiba Components	Sep. 25, 1998	EC98J1065 (JACO)
	Kaga Toshiba Electronics	Sep. 25, 1998	EC98J1071 (JACO)
	Buzen Toshiba Electronics	Jan. 27, 1998	EC97J1171 (JACO)
Overseas	Toshiba Semiconductor GmbH	Apr. 08, 1997	1453281-01 (DAR)
	Toshiba Electronics Malaysia Sdn. Bhd.	Sep. 26, 1997	T0066301097 (SIRIM)
	Toshiba Semiconductor (Thailand) Co., Ltd.	Sep. 25, 1998	98011/0015 (TISI)

All of the Semiconductor Company manufacturing sites of the Semiconductor Company of Toshiba Corporation, and the Semiconductor Company Head Offices and the Sales Offices in Japan have obtained ISO14001 certification.